



B/DW

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q54431

Toshiro HAYAKAWA, et al.

Appln. No.: 09/315,068

Group Art Unit: 2828

Confirmation No.: 5982

Examiner: Dung T. NGUYEN

Filed: May 20, 1999

For: SEMICONDUCTOR LASER AND METHOD OF MANUFACTURING THE SAME

RESPONSE TO EXAMINER'S STATEMENT FOR REASONS FOR ALLOWANCE

MAIL STOP ISSUE FEE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the November 19, 2004 Notice of Allowance, Applicants respectfully submit the following remarks. In reviewing the Examiner's Statement for Reasons for Allowance, Applicant submits that the Statement appears to import a requirements not specifically recited by independent claim 1.

Respectfully submitted,



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Date: February 8, 2005